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## **Electronic Supplementary Information**

Beryllium Dinitride Monolayer: A Multifunctional Direct Bandgap

Anisotropic Semiconductor with Polymeric Nitrogen, Oxygen

Reduction Catalysis, and Potassium Ion Storage Ability

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#### Calculation of formation energy of α-2D-BeN<sub>2</sub>

The formation energy of  $\alpha$ -2D-BeN<sub>2</sub> is calculated as:

$$E_{f-BeN_2} = \frac{E_{BeN_2} - E_{Be} - E_{N_2}}{3} \# (Eq S1)$$

where  $E_{BeN_2}$ ,  $E_{Be}$ , and  $E_{N_2}$  are the energy of  $\alpha$ -2D-BeN<sub>2</sub>, Be atom in its bulk metal and N<sub>2</sub> molecule, respectively.

### Calculation of the interlayer binding energy of the freestanding bilayers

The interlayer binding energy of the freestanding bilayers is calculated as:

$$E_{bind} = \frac{E_{bi} - 2E_{mono}}{S} \# (Eq S2)$$

where  $E_{bi}$ ,  $E_{mono}$  and S are the total energy of the bilayer, total energy of each monolayer, and the area of bilayer structure, respectively.

#### Calculation of Young's stiffness and Poisson's ratio

The in-plane Young's stiffness  $Y(\theta)$  and Poisson's ratio  $v(\theta)$  are calculated as functions of  $\theta$  based on the equations as listed below <sup>1</sup>:

$$Y(\theta) = \frac{C_{11}C_{22} - C_{12}^{2}}{C_{11}sin^{4}\theta + C_{22}cos^{4}\theta + \left(\frac{C_{11}C_{22} - C_{12}}{C_{66}} - 2C_{12}\right)cos^{2}\theta sin^{2}\theta} \#(Eq S3)$$

$$v(\theta) = \frac{\left(C_{11} + C_{12} - \frac{C_{11}C_{22} - C_{12}^{2}}{C_{66}}\right)cos^{2}\theta sin^{2}\theta - C_{12}sin^{4}\theta - C_{12}cos^{4}\theta}{C_{11}sin^{4}\theta + C_{22}cos^{4}\theta + \left(\frac{C_{11}C_{22} - C_{12}}{C_{66}} - 2C_{12}\right)cos^{2}\theta sin^{4}\theta} \#(Eq S4)$$

#### **Calculation of carrier mobility**

According to the DP theory <sup>2</sup>, the carrier mobility of a 2D structure is calculated as:  $\mu_{2D} = \frac{e\hbar^3 C_{2D}}{k_B T m^* m_d (E_1)^2} \# (Eq S5)$ 

where e,  $\hbar$ , and  $k_B$  are the electron charge, reduced Planck constant, and Boltzmann constant, respectively.  $C_{2D}$  are the elastic moduli, T is the temperature (300 K),  $m^*$  is

the effective mass along the transport direction, which can be obtained by fitting the band structure at the CBM and VBM, and  $m_d = \sqrt{m_x^* m_y^*}$  is the average effective mass.  $E_l$  is the deformation potential constant, which is the key to the magnitude of mobility, defined by  $E_l = \partial E_{edge} / \partial \varepsilon$ , where  $E_{edge}$  is the energy of the band edge and  $\varepsilon = \Delta l / l_0$ . The strain range is from -0.6% to +0.6% with an interval of 0.2%. This method has been widely applied in many monolayers <sup>3-6</sup>.

#### Calculation of optical absorption.

According to the frequency-dependent permittivity of  $\varepsilon(\omega) = \varepsilon_1(\omega) + i\varepsilon_2(\omega)$ , the absorption coefficient was obtained based on the following equation <sup>7, 8</sup>:

$$\alpha(\omega) = \frac{\sqrt{2}\omega}{c} \left[ \sqrt{\varepsilon_1^2(\omega) + \varepsilon_2^2(\omega)} - \varepsilon_1(\omega) \right]^{1/2} \# (Eq S6)$$

# Calculation of free energy changes for the oxygen reduction/evolution reaction (ORR/OER)

The ORR and OER follow the associative mechanism pathways, as equation below:  $O_2 \rightarrow OO * \rightarrow OOH * \rightarrow O * + H_2O \rightarrow OH * + H_2O \rightarrow 2H_2O\#(Eq S7)$   $2H_2O \rightarrow OH * + H_2O \rightarrow O * + H_2O \rightarrow OOH * \rightarrow OO * \rightarrow O_2 \#(Eq 8)$ where, the \* is the  $\alpha$ -2D-BeN<sub>2</sub>.

To study the catalytic capabilities of  $\alpha$ -2D-BeN<sub>2</sub>, we employed a supercell combined with the computational hydrogen electrode (CHE) methodology <sup>9</sup>. The free energy ( $\Delta$ G) of electrochemical reaction is expressed as:

$$\Delta G = \Delta E + \Delta E_{ZPE} - \Delta TS + \Delta G_{pH} + \Delta G_U \# (Eq S9)$$

where,  $\Delta E$  represents the reaction energy;  $E_{ZPE}$  and S respectively denote zero-point energy and entropy. The influences of pH and electrode potential (U) can be calculated by the equation as:  $\Delta GpH = 0.0592 \times pH$  and  $\Delta G = -eU$ . In this study, the temperature (T) for the system is 298.15 K, and pH is 0 at an electrode potential (U) of 0 V. The limiting potential of ORR (UL,ORR) is defined as the minimum value among ( $-\Delta G1$ ,  $-\Delta G2$ ,  $-\Delta G3$ ,  $-\Delta G4$ ). The limiting potential of OER (UL,OER) is defined as the maximum value among ( $\Delta G1$ ,  $\Delta G2$ ,  $\Delta G3$ ,  $\Delta G4$ ). The  $E_{ZPE}$ /-TS of H<sub>2</sub> and H<sub>2</sub>O(l) are 0.28/-0.404 eV and 0.68/-0.216 eV at 298.15 K and 1 atm obtained from the NIST database,10 and the Gibbs free energy of H<sub>2</sub> and H<sub>2</sub>O(l) are calculated as -14.52 eV and -6.90 eV, respectively.

#### Calculation details of K-ion storage performances

The adsorption energy (E<sub>ads</sub>) was calculated as following:

$$E_{ads} = E_{K@\alpha - 2D - BeN_2} - E_{\alpha - 2D - BeN_2} - E_K \# (Eq \ S10)$$

where  $E_{K@\alpha - 2D - BeN_2}$  and  $E_{\alpha - 2D - BeN_2}$  are total energy of adsorbed and bare  $\alpha$ -2D-BeN<sub>2</sub>, respectively.  $E_K$  is the energy of a K atom in K metal bulk.

The formation energy  $(E_f)$  is calculated by the following equation:

$$E_f = \frac{E_{K_x BeN_2} - xE_K - E_{BeN_2}}{x+1} \# (Eq \ S11)$$

where  $E_{K_x BeN_2}$  represents the energy of the system with x K ions. The average stepwise adsorption energy (E<sub>step</sub>) was calculated as following:

$$E_{step} = \frac{E_{K_n BeN_2} - E_{K_m BeN_2}}{n - m} - E_K \# (Eq \, S12)$$

where  $E_{K_n BeN_2}$  and  $E_{K_m BeN_2}$  are total energy of  $\alpha$ -2D-BeN<sub>2</sub> with n and m K ions, respectively.

The maximum specific capacities  $(C_M)$  is estimated using the following formula:

$$C_M = \frac{cxF}{m_{\alpha - 2D - BeN_2}} \# (Eq S13)$$

where c is the number of valence electrons (c = 1 for K), x is the number of K ions adsorbed per formula unit, F is the Faraday constant (26801 mAh·mol<sup>-1</sup>), and  $m_{\alpha-2D-BeN_2}$  is the molar weight of chemical formula BeN<sub>2</sub>.

The open-circuit voltage (VOC) of these stable systems can then be calculated using the following formula:

$$V_{OC} = -\frac{E_{step}}{e} \# (Eq S14)$$

where the  $E_{step}$  is the average stepwise adsorption energy between the stable adsorption conformers and e is the elementary charge.

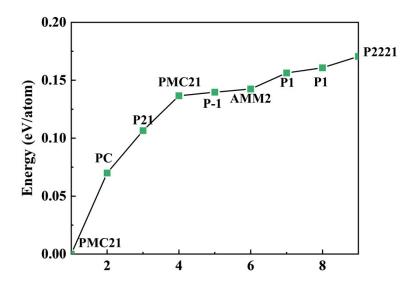


Fig. S1. The energy difference between  $\alpha$ -2D-BeN<sub>2</sub> and 2D isomers of BeN<sub>2</sub>, which are found by the CALYPSO code with atom number set as Be : N = 4 : 8.

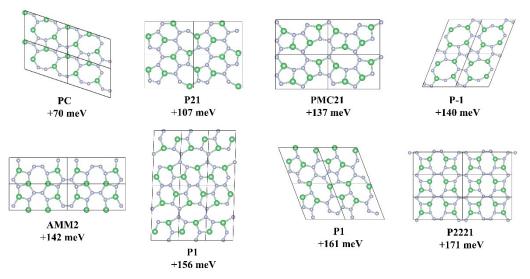
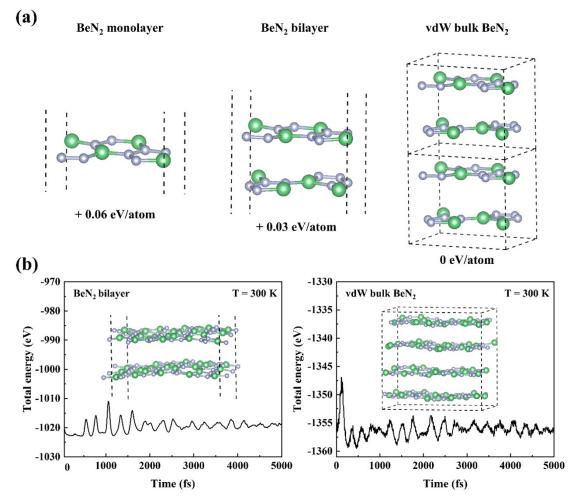


Fig. S2. The  $\alpha$ -2D-BeN<sub>2</sub> and isomers of 2D BeN<sub>2</sub> found by the CALYPSO structure search code, where the number indicate the energy difference based on  $\alpha$ -2D-BeN<sub>2</sub> as a reference.



**Fig. S3.** (a) Structural configurations and relative energies (vs. vdW bulk BeN<sub>2</sub>) of  $\alpha$ -2D-BeN<sub>2</sub> monolayer, bilayer, and bulk phases. (b) the changes in total energy of  $\alpha$ -2D-BeN<sub>2</sub> bilayer, and vdW bulk BeN<sub>2</sub>, along with structural snapshots after the 5 ps AIMD simulations at 300 K. The supercell used in the AIMD simulation is 2 × 3 × 1, and 2 × 2 × 2, respectively.

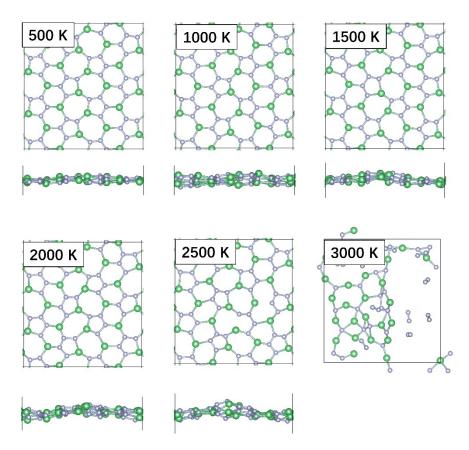


Fig. S4. The snapshots of  $\alpha$ -2D-BeN<sub>2</sub> structures after AIMD simulations

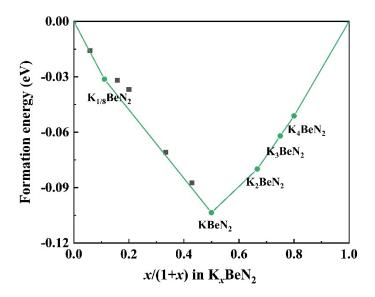


Fig. S5. Formation energy convex hull of  $K_x BeN_2$  structures at different K ion concentrations.

#### The carrier mobilities of α-2D-BeN<sub>2</sub>

The calculated details of all parameters mentioned above in the "Calculation of carrier mobility" part are listed in the Table S1. For electron carriers, the effective mass is 0.96/0.61 m<sub>e</sub> with high mobility of  $0.55/6.6 \times 10^4 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$  along direction*a/-b*, respectively. With comparison, the hole carrier has close effective mass of -0.60/-0.81 m<sub>e</sub> with relatively smaller mobility of  $1.3/8.3 \times 10^3 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ , along direction-*a/b*, respectively. The highest value is lower than that of graphene ( $3.4 \times 10^5 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ ) <sup>10</sup> and *h*-BeN<sub>2</sub> ( $3.4 \times 10^5 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ ) <sup>4</sup>, but higher than that of BP monolayer ( $2.6 \times 10^4 \text{ cm}^2\text{V}^{-1}\text{s}^{-1}$ ) <sup>5</sup>.

**Table. S1.** The calculated 2D elastic moduli ( $C_{2D}$ ), effective mass (m\*), average effective mass (m<sub>d</sub>), deformation potential constant ( $E_l$ ), and carrier mobility of 2D structures ( $\mu_{2D}$ ) along the transport direction (axial *a* and *b*, here). The "m<sub>e</sub>" is the rest mass of a static electron.

Carrier	$C_{2D}$ (N/m)	<i>m</i> *(m <sub>e</sub> )	$m_d (m_e)$	$E_l$ (eV)	$\mu_{2D}$ (cm <sup>2</sup> V <sup>-1</sup> s <sup>-1</sup> )
type					
Hole_a	153.8	-0.600	0.698	-2.414	1342
Electron_a	153.8	0.963	0.764	-0.896	5546
Hole_b	145.4	-0.813	0.698	-0.813	8256
Electron_b	145.4	0.606	0.764	-0.318	66143

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